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APPLICATION N	0.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/632,850		08/04/2003	Shinji Kobayashi	900-471	3441	
23117	7590	08/30/2005		EXAM	EXAMINER	
		DERHYE, PC	DINH, PAUL			
	901 NORTH GLEBE ROAD, 11TH FLOOR ARLINGTON, VA 22203			ART UNIT	PAPER NUMBER	
				2825	<u> </u>	
				DATE MAILED: 08/30/2009	5	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)	
Office Action Commence	10/632,850	KOBAYASHI, SHINJI	
Office Action Summary	Examiner	Art Unit	
	Paul Dinh	2825	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet with the c	orrespondence address	
A SHORTENED STATUTORY PERIOD FOR REPLY THE MAILING DATE OF THIS COMMUNICATION.  - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication.  - If the period for reply specified above is less than thirty (30) days, a reply If NO period for reply is specified above, the maximum statutory period v  - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timed within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	ely filed s will be considered timely. the mailing date of this communication. O (35 U.S.C. § 133).	
Status ·		·	
1) Responsive to communication(s) filed on 04 At	ugust 2005.		
	action is non-final.		
3) Since this application is in condition for allowar closed in accordance with the practice under E	nce except for formal matters, pro		
Disposition of Claims			
<ul> <li>4)  Claim(s) 1-8 is/are pending in the application.</li> <li>4a) Of the above claim(s) 8 is/are withdrawn from 5)  Claim(s) is/are allowed.</li> <li>6)  Claim(s) 1-7 is/are rejected.</li> <li>7)  Claim(s) is/are objected to.</li> <li>8)  Claim(s) are subject to restriction and/or</li> </ul>	·		
Application Papers			
9) ☐ The specification is objected to by the Examine 10) ☑ The drawing(s) filed on 04 August 2003 is/are:	a)⊠ accepted or b)□ objected t	•	
Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct  11) The oath or declaration is objected to by the Ex	ion is required if the drawing(s) is obj	ected to. See 37 CFR 1.121(d).	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of:  1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prior application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received in Application rity documents have been receive u (PCT Rule 17.2(a)).	on No d in this National Stage	
Attachment(s)  1) Notice of References Cited (PTO-892)  2) Notice of Draftsperson's Patent Drawing Review (PTO-948)  3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08)  Paper No(s)/Mail Date 8/4/03.	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:		

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#### **DETAILED ACTION**

This is a response to the election filed on 8/4/05. The examiner acknowledges:

The election of product group I claims 1-7 without traverse.

The non-elected method claim 8 is retained for possible divisional application.

Thus, claim 8 is withdrawn from further consideration.

The applicant is required to cancel the non-elected claim in the next communication, the restriction is final.

### Claim Objections

In claim 1, line 1; "multiple exposure" should be changed to - - multiple exposures - -.

## Claim Rejections - 35 USC § 112

The following is a quotation of the first paragraph of 35 U.S.C. 112:

The specification shall contain a written description of the invention, and of the manner and process of making and using it, in such full, clear, concise, and exact terms as to enable any person skilled in the art to which it pertains, or with which it is most nearly connected, to make and use the same and shall set forth the best mode contemplated by the inventor of carrying out his invention.

Claim 1-7 is rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the enablement requirement. The claim(s) contains subject matter, which was not described in the specification in such a way as to enable one skilled in the art to which it pertains, or with which it is most nearly connected, to make and/or use the invention.

Claim 1 is rejected because the combination of limitations "a mask pattern under a design having the width of an aperture pattern smaller than the width of a light-shielding pattern" on lines 3-5 and "the mask pattern under a design having the width of an aperture pattern greater than the width of a light-shielding pattern" on lines 6-8 finds no clear support in the specification.

Claims 2-7 are rejected because they depend from on claim 1.

The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter, which the applicant regards as his invention.

Claims 1-7 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claims 1 is rejected because:

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a. The phrase "as in case" renders the claim indefinite because it is unclear whether the limitation(s) following the phrase are part of the claimed invention. See MPEP § 2173.05(d).

- b. The combination of limitations "a mask pattern under a design having the width of an aperture pattern smaller than the width of a light-shielding pattern" on lines 3-5 and "the mask pattern under a design having the width of an aperture pattern greater than the width of a light-shielding pattern" on lines 6-8 is unclear, does not make sense, contradicting, and thus indefinite.
- c. It is not clear that "mask pattern" on line 1 is the same as "mask pattern" on line 3. Claim 1 must define any differences between these two for clarification and add "said/the" and "first/second" to these two accordingly for clarification.
- d. It is not clear that "pattern pitch" on line 2 is the same as "pattern pitch" on line 6. Claim 1 must define any differences between these two for clarification and add "said/the" and/or "first/second" to these two accordingly for clarification.
- e. It is not clear that "aperture pattern" on line 4 is the same as "aperture pattern" on line 7. Claim 1 must define any differences between these two for clarification and add "said/the" and/or "first/second" to these two accordingly for clarification.
- f. It is not clear that "light-shielding pattern" on lines 4-5 is the same "light-shielding pattern" on line 8. Claim 1 must define any differences between these two for clarification and add "said/the" and/or "first/second" to these two accordingly for clarification.

Claims 2-7 are rejected because they depend from claim 1.

Claims 2-3 are rejected because it is not clear that "the mask pattern" in these claims refer to "mask pattern" on line 1 of claim 1 or "mask pattern" on line 3 of claim 1.

Claims 4-5 are rejected because it is not clear that "the aperture pattern" in these claims refer to "aperture pattern" on line 4 of claim 1 or "aperture pattern" on line 7 of claim 1.

Claims 6-7 are rejected because it is not clear that "the light-shielding pattern" in these claims refer to "light-shielding pattern" on lines 4-5 of claim 1 or "light-shielding pattern" on line 8 of claim 1.

#### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Paul Dinh whose telephone number is 571-272-1890. The examiner can normally be reached on Monday to Friday from 8:30am to 5:00pm.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Matthew S. Smith can be reached on 571-272-1907. The fax number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Yaul Divh

Paul Dinh

Patent Examiner